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# Trends of Machine Learning in Multidisciplinary Engineering Processes

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Deadline for manuscript submissions:

closed (30 June 2023)

### **Message from the Guest Editors**

Dear Colleagues,

This Special Issue on "Trends of Machine Learning in Multidisciplinary Engineering Processes" aims to attract paper submissions to provide a cohesive and novelty perspective on ML methods that will be integrated in multidisciplinary engineering processes to resolve the challenges in the industrialization and communications. Topics of interest include, but are not limited to:

- The development of new ML algorithms/applications in manufacturing processes.
- The development of new networking-based ML algorithms/applications.
- The development of new security-based ML algorithms/applications.
- The development of new healthcare-based ML algorithms/applications.
- The development of new educational-based ML algorithms/applications.
- The development of new sustainable agriculturebased ML algorithms/applications.
- The development of new education-based ML algorithms/applications.











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## **Message from the Editor-in-Chief**

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